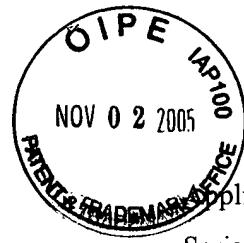


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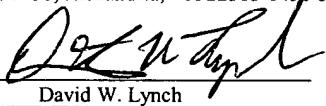


PATENT

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant: CYRILLE et al. Examiner: Culbert, R.
Serial No.: 10/633,765 Group Art Unit: 1763
Filed: August 4, 2003 Docket No.: HSJ920030027US1
Title: (HITG.025PA)
METHOD FOR PROVIDING A LIFTOFF PROCESS USING A SINGLE LAYER
RESIST AND CHEMICAL MECHANICAL POLISHING AND SENSOR
FORMED THEREWITH

CERTIFICATE UNDER 37 CFR 1.8: The undersigned hereby certifies that this correspondence and the papers, as described hereinabove, are being deposited in the United States Postal Service, as first class mail, in an envelope addressed to: Mail Stop Amendment, Commissioner for Patents, P.O. Box 1450, Alexandria, VA 22313-1450 on October 27, 2005.

By: 

David W. Lynch

REQUEST FOR RECONSIDERATION

MAIL STOP AMENDMENT
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Dear Sir:

In response to the Office Action dated July 27, 2005, reconsideration and allowance of the application are respectfully requested in view of the remarks below.

Amendments to the claims begin on page 2 of this paper.

Remarks begin on page 6 of this paper.